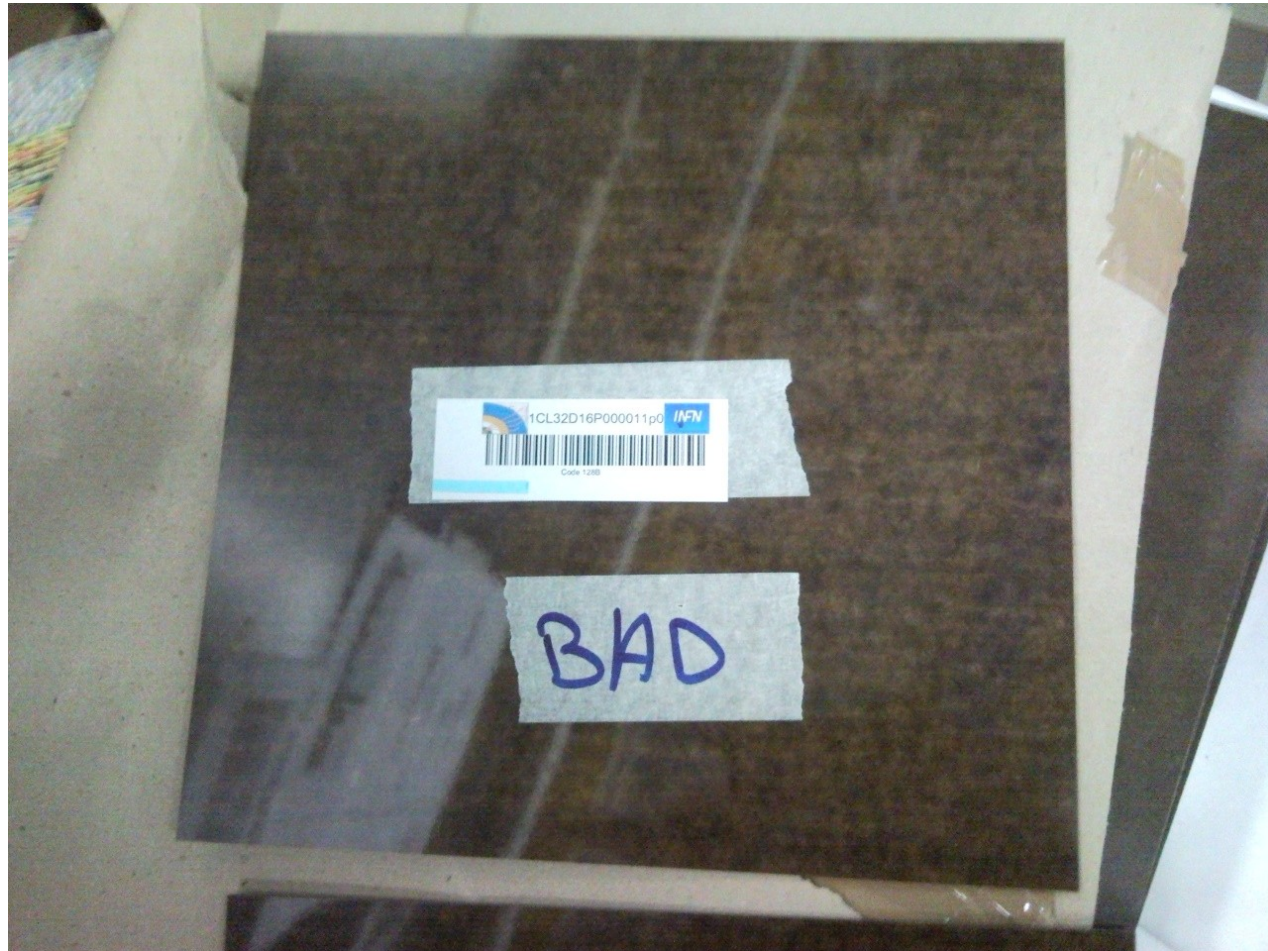


HPL Trendline Update

Puricelli production:
June – December
2010

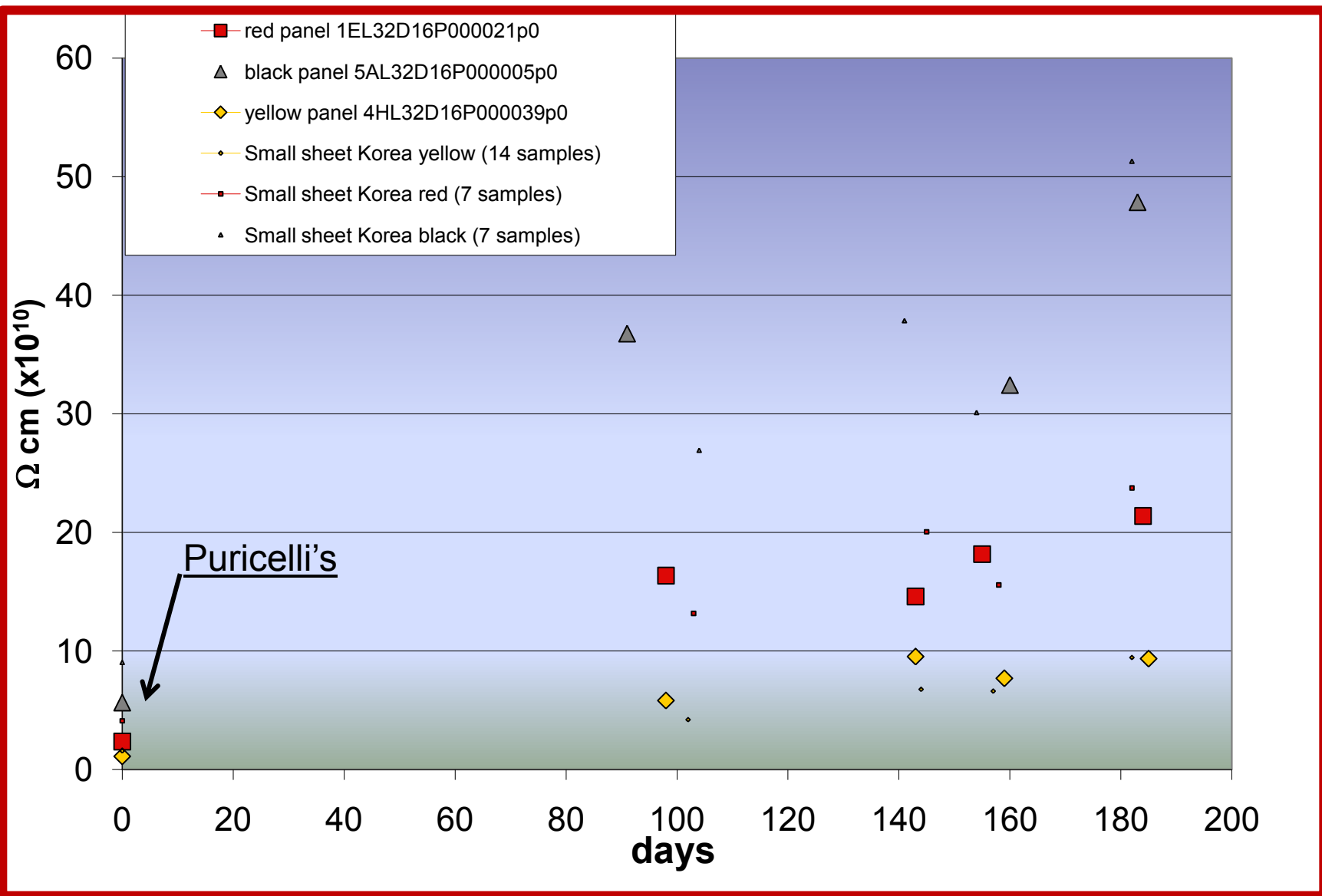
G. Belli, P. Vitulo
RPC Upscope 14 Dec. 2010

Puricelli Production June 2010



Resistivity Values from June to December 2010

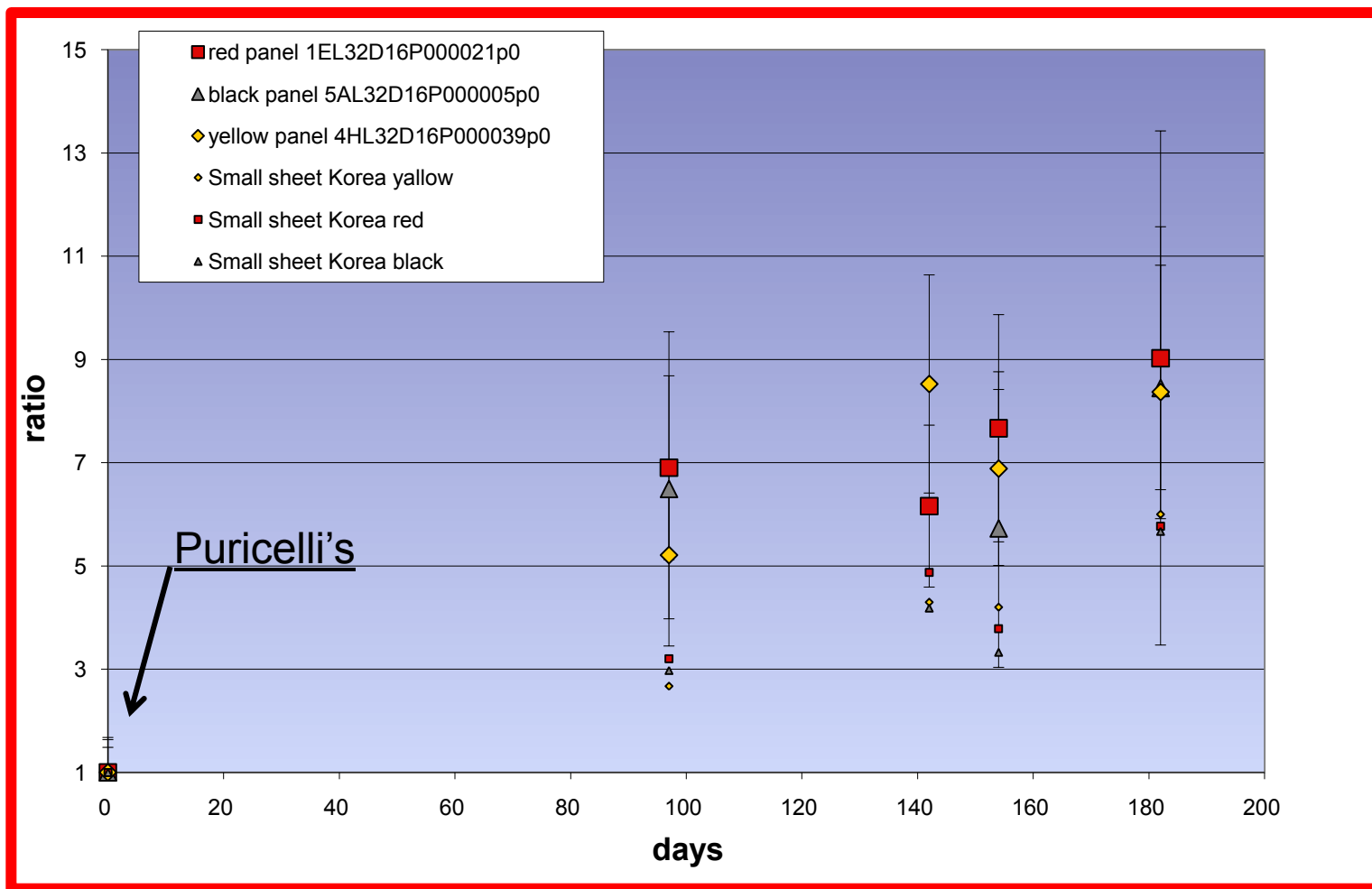
(all panels)



Normalized Resistivity vs Time (values normalized to the initial value)

All panels and samples arrived in Pavia.

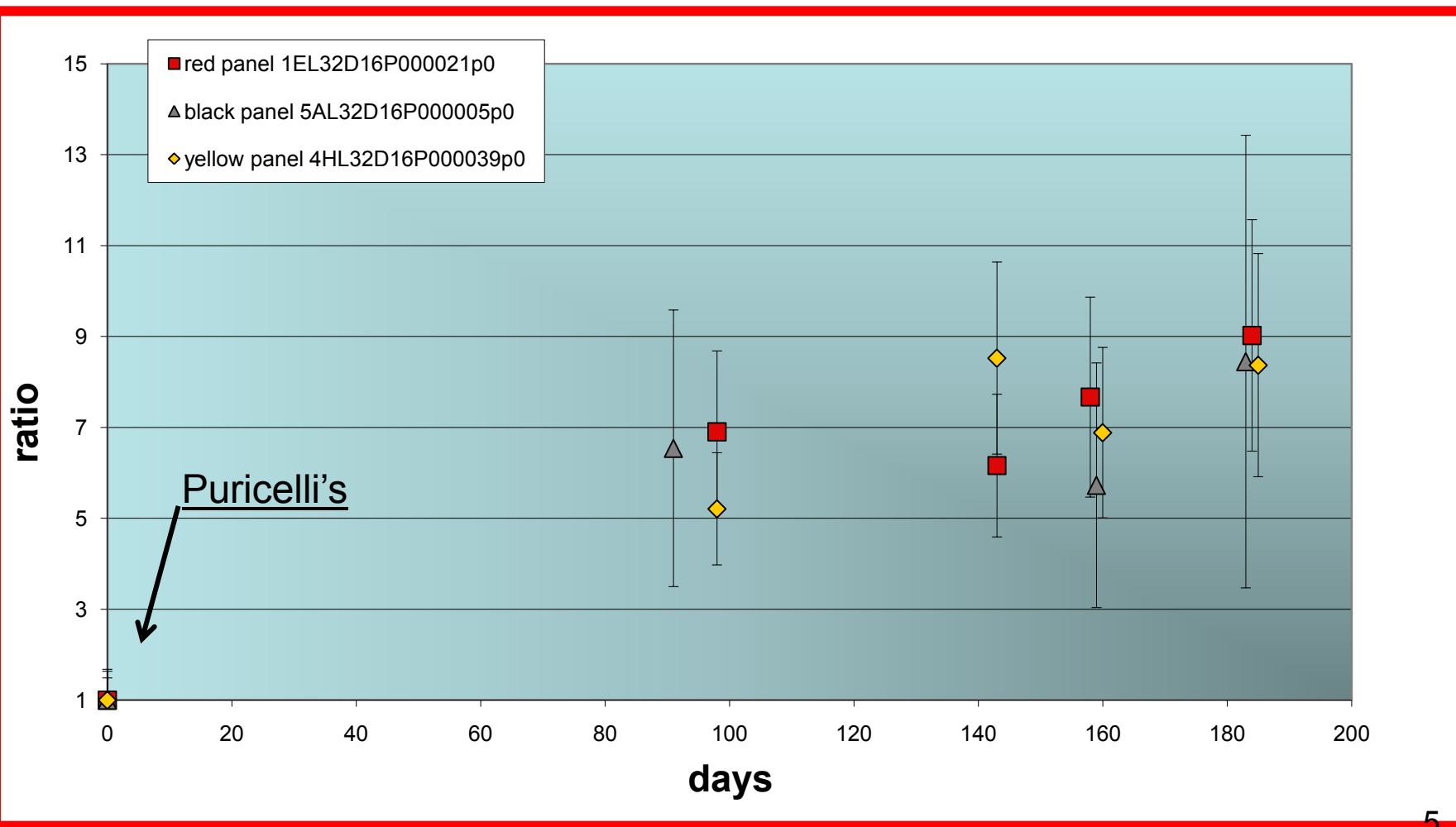
Displayed values refer to average and standard deviation



Normalized Resistivity vs Time

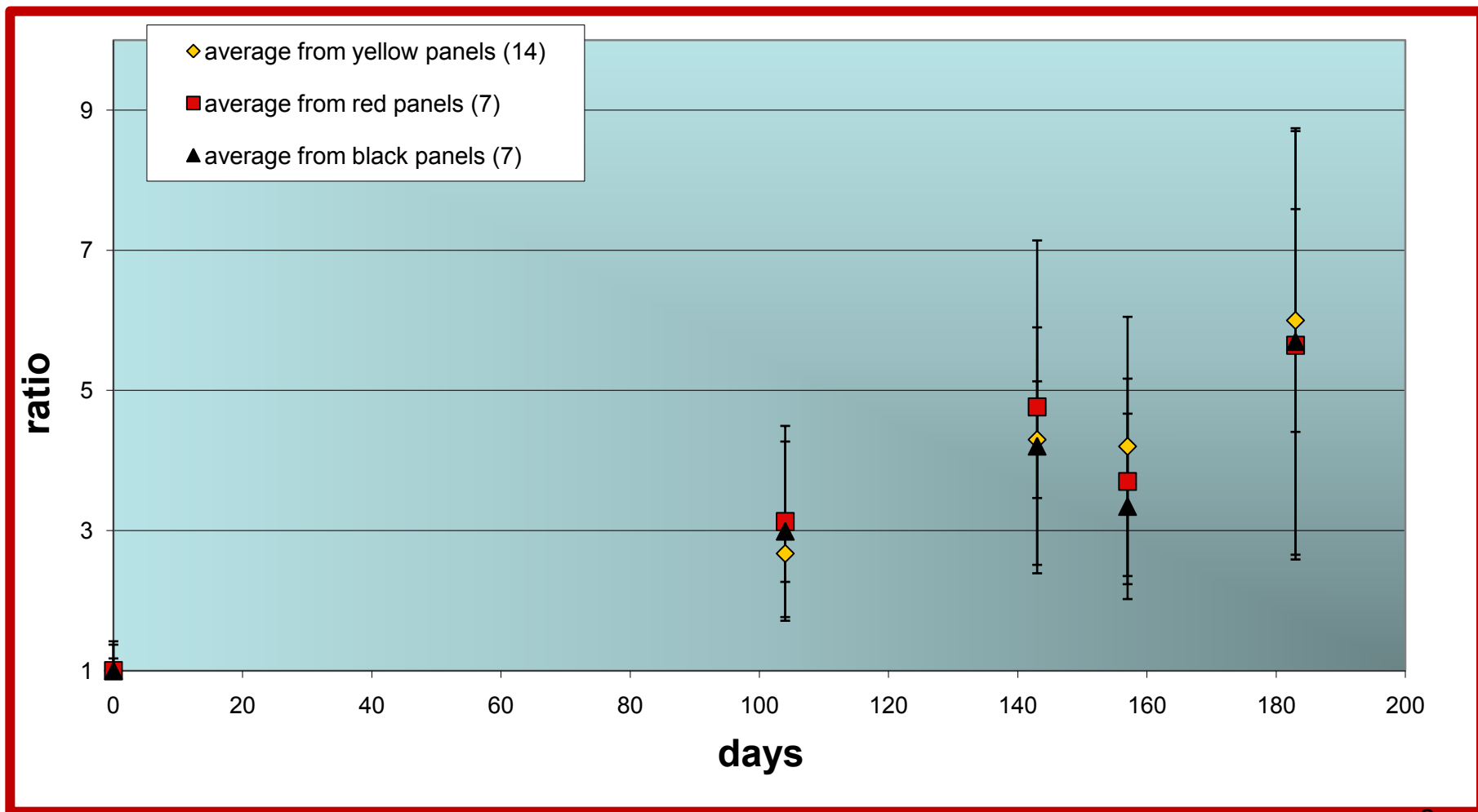
3 entire panels: 128 measurements/panel

Displayed values refer to average and standard deviation

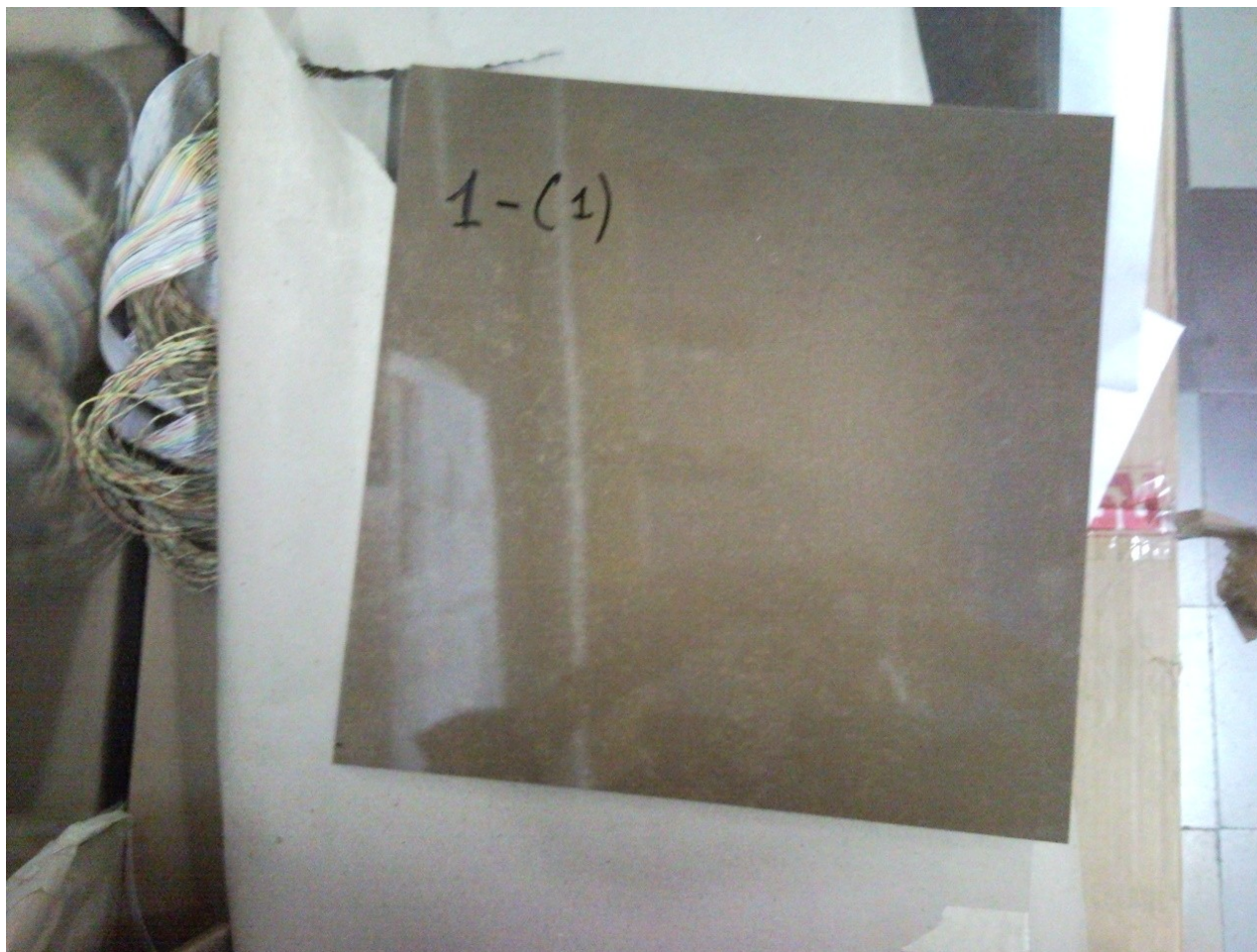


Normalized Resistivity vs Time

(small samples from 28 panels cut for gap production)



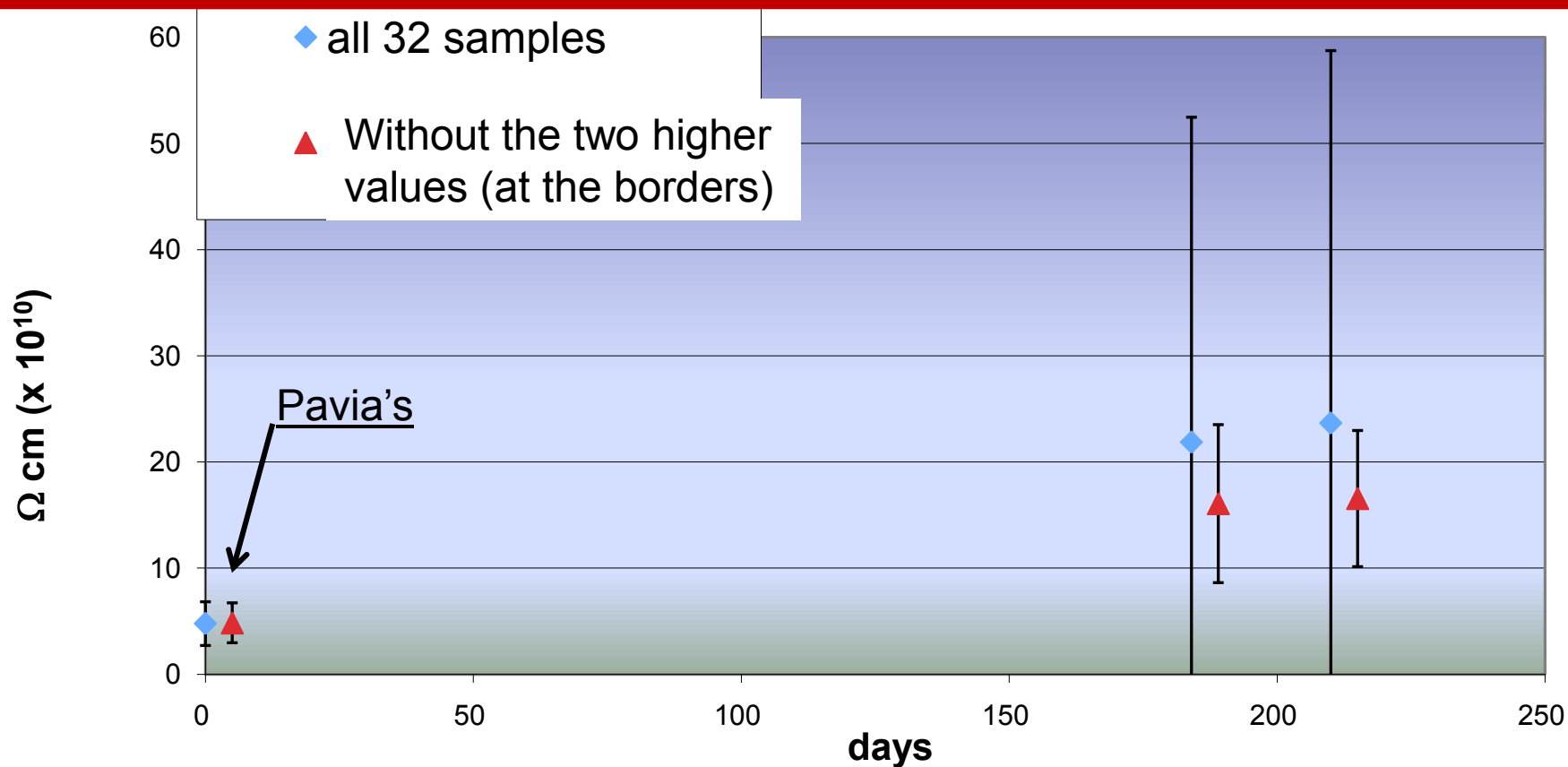
Puricelli Production: March-May 2010



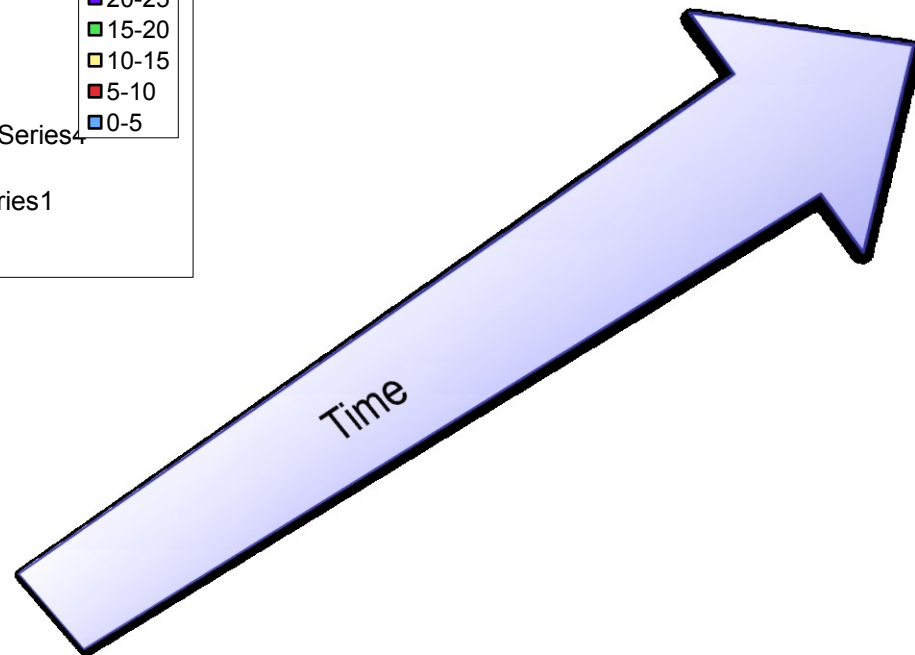
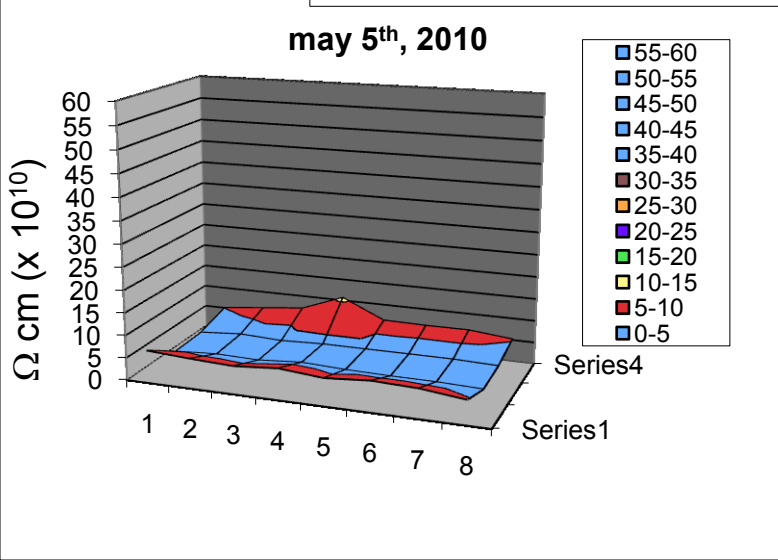
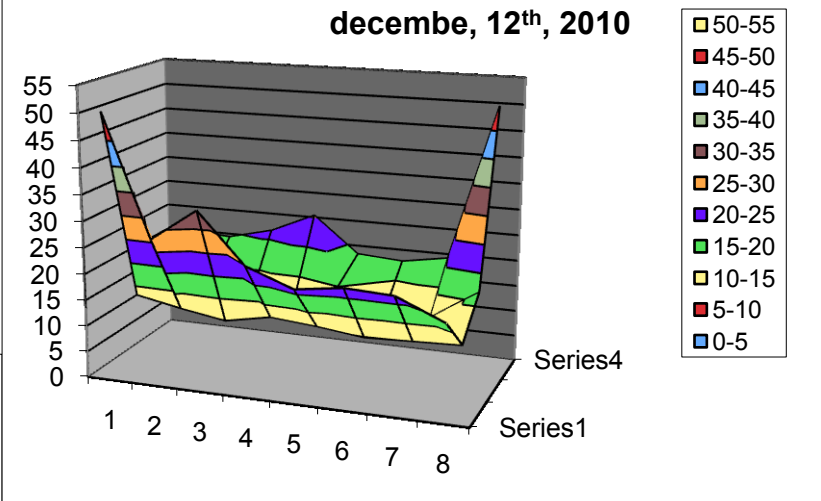
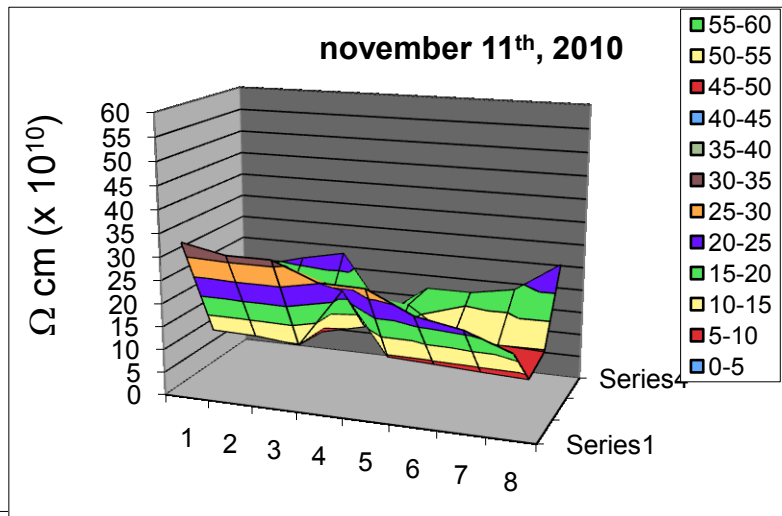
Bakelite Resistivity

Puricelli Production: panel # 1 (2010)

(divided in 32 samples)



Panel # 1

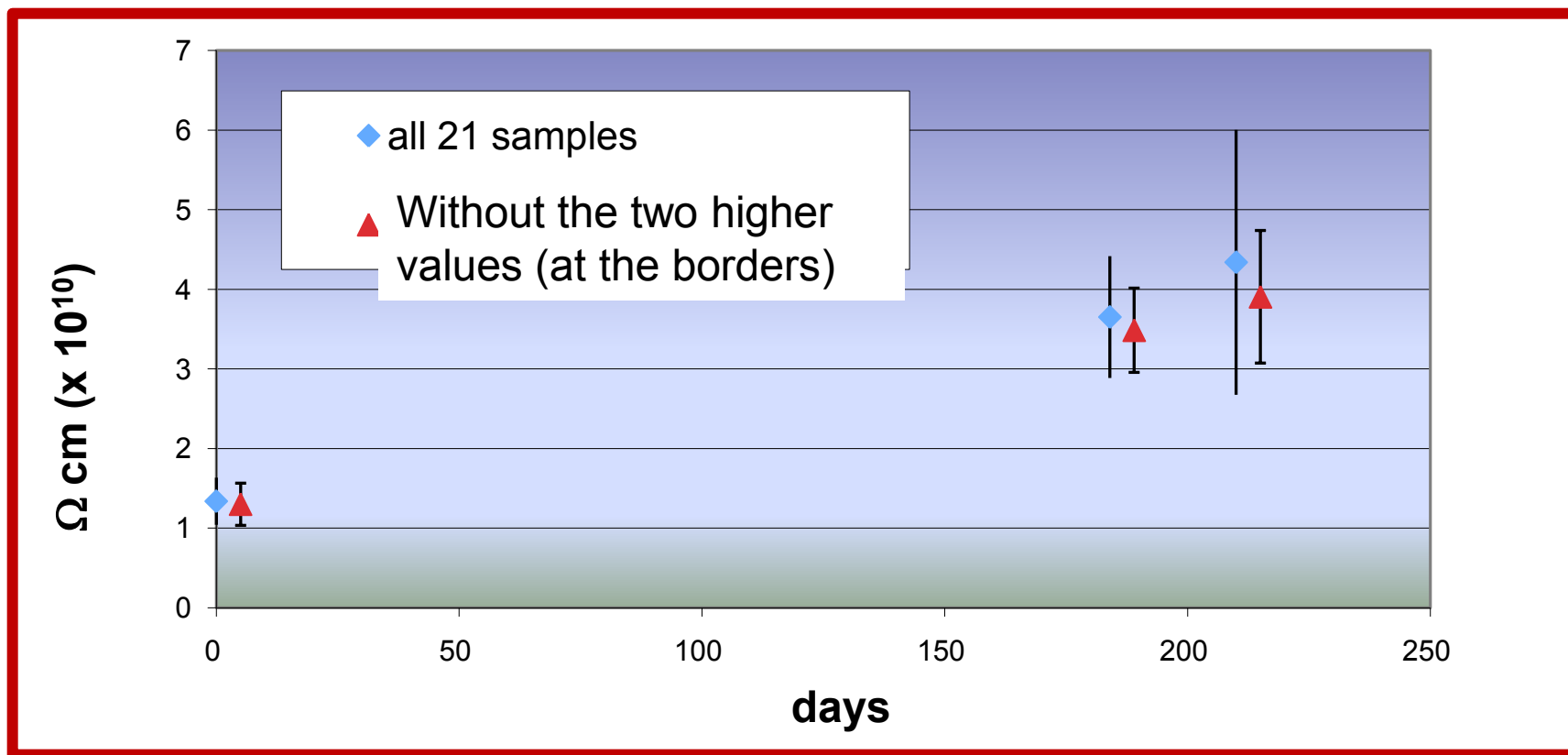


Puricelli Production: March-May 2010



Bakelite Resistivity

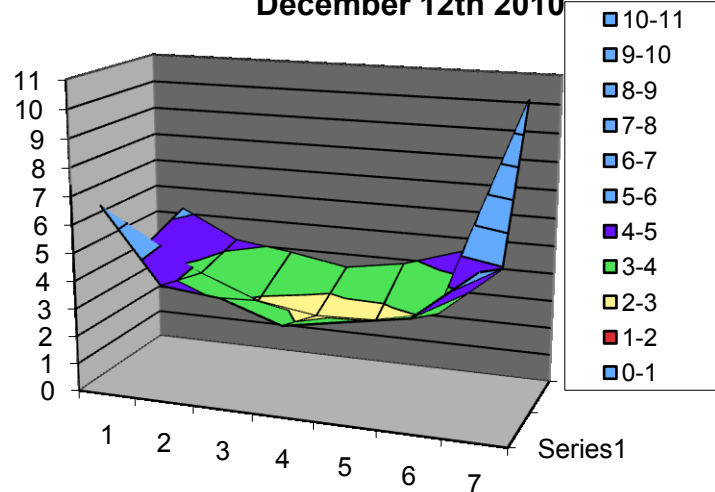
Puricelli Production: panel # 2 (2010)
(divided in 21 samples)



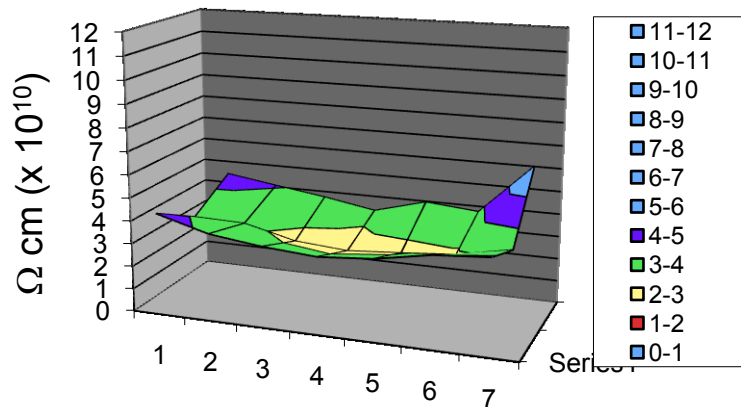
Panel # 2

Ω cm ($\times 10^{10}$)

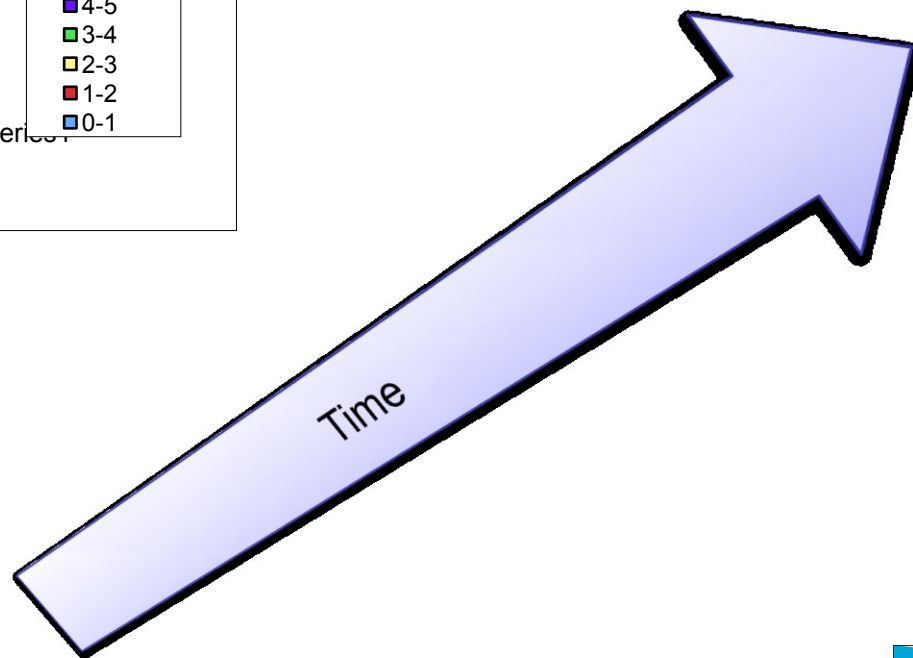
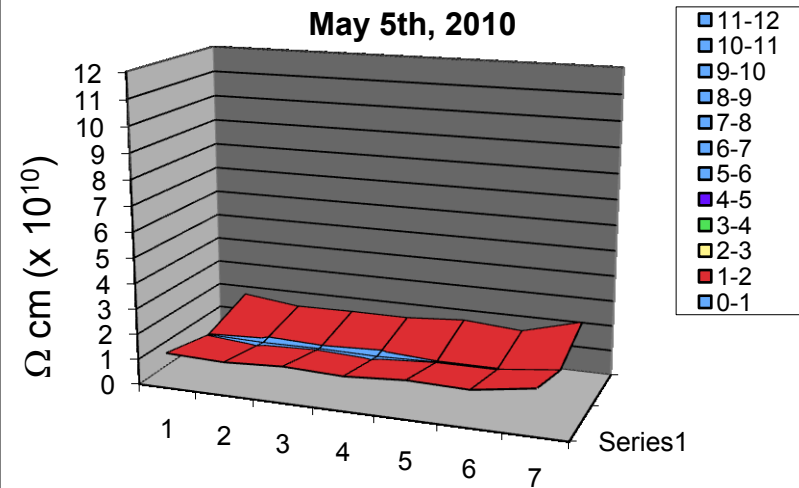
December 12th 2010



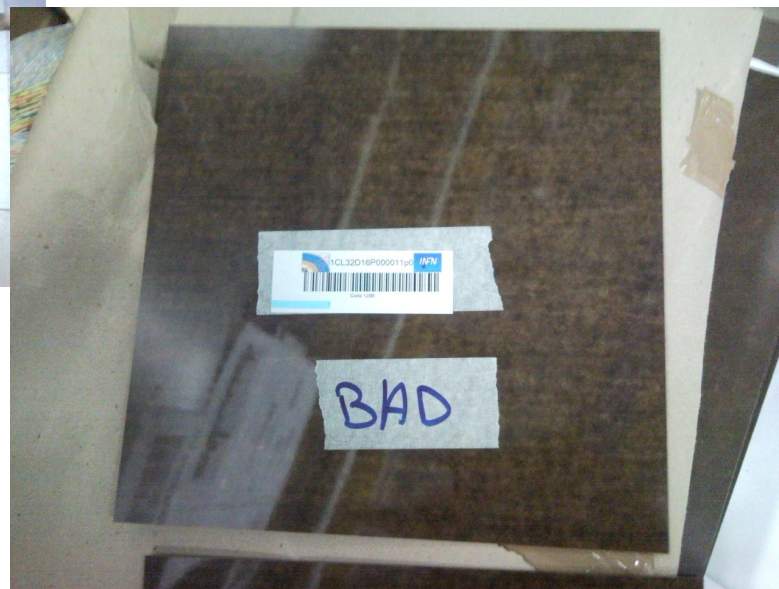
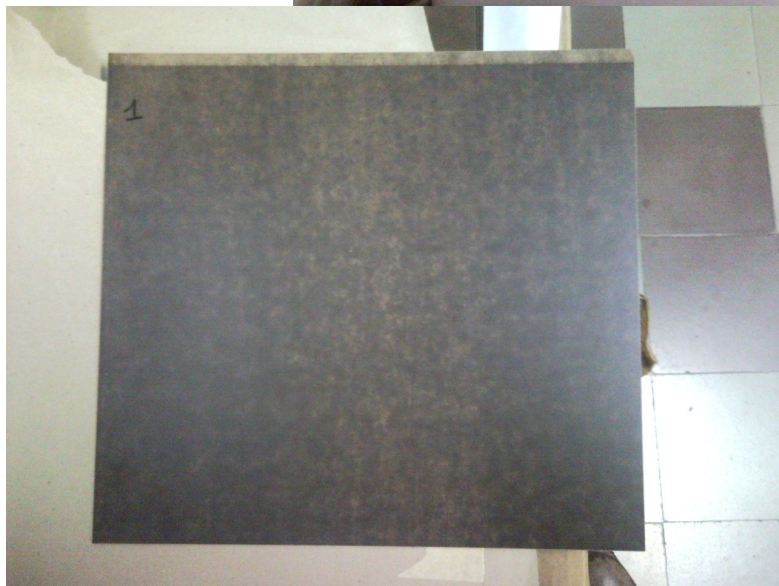
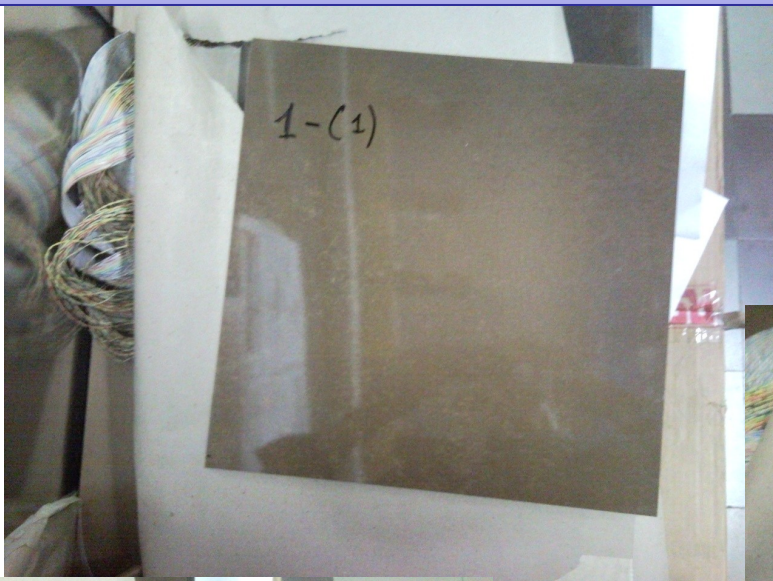
November 11th 2010



May 5th, 2010



Three different HPLs for three different behaviors...



Questions for Puricelli (.....that Panpla never answered...):

- 1) What is the difference between the three panels ? Maybe is time to ask them for some (not all) of the main production parameters: Percentage of volatile ? Temperature at press ? Pressure at press...? So maybe we can compare the measurements with some of them and maybe find some correlations (if any)
- 2) Could the resistivity rise be due to a slow humidity or volatile release ?
- 3) Can they explain how they control the production?
- 4) When they measure the resistivity ? Just at the press exit ?